

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

EXPRESS MAIL NO. EV809338217US

Applicant : Nam Hun Kim  
Application No. : N/A  
Filed : September 22, 2006  
Title : PLASMA CHAMBER HAVING PLASMA SOURCE COIL AND  
METHOD FOR ETCHING THE WAFER USING THE SAME  
Grp./Div. : N/A  
Examiner : N/A  
Docket No. : 58409/N305

INFORMATION DISCLOSURE STATEMENT  
37 CFR § 1.97(b)

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

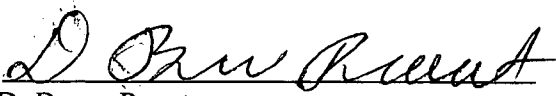
Post Office Box 7068  
Pasadena, CA 91109-7068  
September 22, 2006

Commissioner:

In compliance with the duty of disclosure under 37 CFR §§ 1.56, 1.97 and 1.98, and in accordance with the provisions in the Manual of Patent Examining Procedure §§ 609 and 707.05(b), enclosed is FORM PTO/SB/08A/B listing the references that are known to applicant. Copies of each of the listed Foreign Patent Documents and Other Documents are enclosed. This filing is timely because it is made during one of the periods described in 37 CFR § 1.97(b).

It is respectfully requested that the listed references be considered in the examination of this application and identified on the list of references cited on the patent issuing for this application. Applicant also requests that an initialed copy of FORM PTO/SB/08A/B be entered in the application file and returned to applicant with the next communication from the Office in accordance with MPEP § 609.

Respectfully submitted,  
CHRISTIE, PARKER & HALE, LLP

By   
D. Bruce Prout  
Reg. No. 20,958  
626/795-9900

DBP/aam  
Enclosures: Form PTO/SB/08A/B, w/references  
AAM PAS702141.1-\*09/22/06 11:33 AM

FORM PTO/SB/08A/B (10-01) Substitute for PTO-1449A/B	<b>Attorney Docket Number</b> 58409/N305	
<b>INFORMATION DISCLOSURE</b>  <b>STATEMENT BY APPLICANT</b>  (use as many sheets as necessary)	<b>Application Number</b> N/A	
	<b>Filing Date</b> September 22, 2006	
	<b>Applicant(s)</b> Nam Hun Kim	
	<b>Group Art Unit</b> N/A	
	<b>Examiner Name</b> N/A	

U.S. PATENT DOCUMENTS				
EXAMINER INITIALS	Cite No. <sup>1</sup>	DOCUMENT NUMBER Number - Kind Code <sup>2</sup> (If Known)	Publication Date MM-DD-YYYY	Name of Patentee
/DD/		5,690,781	11-25-1997	Yoshida et al.
/DD/		6,534,007 B1	03-18-2003	Blonigan et al.

FOREIGN PATENT DOCUMENTS					
EXAMINER INITIALS	Cite No. <sup>1</sup>	FOREIGN PATENT DOCUMENT Country Code <sup>3</sup> - Number <sup>4</sup> - Kind Code <sup>5</sup> (If Known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	T <sup>6</sup> (✓)
/DD/		JP 8-88190	04-02-1996	Yoshida et al.	Patent Abstracts of Japan and Corresponding U.S. 5690781 Above
/DD/		JP 2002-110642	04-12-2002	Yasuda	Patent Abstracts of Japan
/DD/		JP 2003-24773	01-28-2003	Takagi et al.	Patent Abstracts of Japan
/DD/		KR 20-0177585	04-15-2000	Lee	Abstract
/DD/		KR 10-2002-0054479	07-08-06	Lee et al.	Korean Patent Abstracts
/DD/		WO 99/06610	02-11-1999	Blonigan et al.	Corresponding U.S. 6534007 Above

OTHER DOCUMENTS		
EXAMINER INITIALS	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article, title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
/DD/		International Search Report, dated 07-11-2005, corresponding to PCT/KR2005/000860
/DD/		Patent Abstracts of Japan, Publication 08-088190, Published 04-02-1996, in the name of Yoshida et al.
/DD/		Patent Abstracts of Japan, Publication 2002-110642, Published 04-12-2002, in the name of Yasuda
/DD/		Patent Abstracts of Japan, Publication 2003-024773, Published 01-28-2003, in the name of Takagi et al.
/DD/		Korean Patent Abstracts, Publication 1020020054479 A, Published 07-08-2002, in the name of Lee et al.

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<b>EXAMINER SIGNATURE</b>	/Duy Vu Deo/ (06/19/2008)	<b>DATE CONSIDERED</b>	
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. <sup>1</sup> Applicant's unique citation designation number (optional). <sup>2</sup> See Kinds Codes of USPTO Patent Documents at www.pto.gov or MPEP 901.4. <sup>3</sup> Enter Office that issued the document, by the two-letter code (WIPO standard ST.3). <sup>4</sup> For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. <sup>5</sup> Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. <sup>6</sup> Applicant is to place a check mark here if English Language Translation is attached.			